	Application No.	Applicant(s)	
	10/666,663	STRUTHERS ET AI	
Notice of Allowability	Examiner	Art Unit	
	Ling-Siu Choi	1713	
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication IGHTS. This application is subject to	plication. If not include will be mailed in due	ed course. <b>THIS</b>
1. This communication is responsive to 12/14/2004.			
2. The allowed claim(s) is/are 48-58.			
3. $\boxtimes$ The drawings filed on <u>18 September 2003</u> are accepted by	the Examiner.		
4. ☐ Acknowledgment is made of a claim for foreign priority una) ☐ All b) ☐ Some* c) ☐ None of the:  1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)).  * Certified copies not received: ☐ Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONY THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  5. ☐ A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give 6. ☐ CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date ☐ (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date ☐ Identifying indicia such as the application number (see 37 CFR 1	e been received. e been received in Application No cuments have been received in this of this communication to file a reply MENT of this application.  sitted. Note the attached EXAMINER es reason(s) why the oath or declara st be submitted. son's Patent Drawing Review ( PTO- s Amendment / Comment or in the Comment	national stage application of the reconstruction of the control of	quirements . IOTICE OF
each sheet. Replacement sheet(s) should be labeled as such in to 7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MATERIAL r	nust be submitted. I	Note the
Attachment(s)  1. ☐ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. Notice of Informal P 6. Interview Summary Paper No./Mail Dat 7. Examiner's Amendr 8. Examiner's Stateme 9. Other	(PTO-413), te nent/Comment	,
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## **DETAILED ACTION**

This Office Action is in response to the Amendment filed December 14, 2004. 1. Claims 1-30 were canceled and claims 31-58 are now pending.

## Examiner's Amendment

2. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CAR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Tom Chen on January 13, 2005.

3. The application has been amended as follows:

Cancel claims 31-47.

## Allowable Subject Matter

- 4. Claims 48-58 are allowed.
- 5. The following is an examiner's statement of reasons for allowance:

The present claims are allowable over the closest references: Struthers (US

Application/Control Number: 10/666,663

Art Unit: 1713

5,366,828).

The present relates to a **method** for forming a nanostructure laded reticulate structure for sorption and desorption of molecular gas, the method comprising

A	polymerizing one or more precursor mixtures to form
	an aerogel
В	supercritically drying the aerogel to remove the liquid components and form
	a monolith aerogel
С	curing the monolith aerogel disposed and sealed into a mold
D	placing the monolith aerogel in a reducing atmosphere and at elevated temperature
	to carbonize the monolith aerogel
D	depositing and bonding a catalyst to sites available on the carbonized aerogel
	to form catalyst islands
Е	growing crystalline graphite precursors from the catalyst islands

(summary of claim 48)

Struthers discloses a negative anode electrode includes micropporous carbon aerogel structures of randomly disposed interengaged carbon fiber in three-dimensional reticulate form and a hydrogen absorbing metal alloy structure throughout and conforming generally to and carried by the micro-porous carbon aerogel, wherein the hydrogen-absorbing metal includes nitrate of chromium, copper, iron, and nickel and the aerogel is obtained by the steps comprising (a) mixing resorcinol, formaldehyde, alcohol, and water in the presence of a base to form an organic sol; (b) gelling the sol by adding a salt such as sodium carbonate, sodium sulfate, potassium chloride, or ammonium nitrate; (c) adding metal nitrate to the alcogel; (d) exchanging

Application/Control Number: 10/666,663

**Art Unit: 1713** 

the solution of alcohol and water within the pores of the organic alcogel; (e) supercritical drying the alcogel to form a metal-laded organic aerogel; and (f) carbonizing the resulting aerogel (abstract; col. 5, lines 24-29 and 50-60; col. 6, lines 15-61). Struthers further disclose that "the metal is established of submicron sizes of metal particles fused together to establish a reticulate disordered multi-component metal alloy structure substantially conforming to the carbon aerogel by subjecting the metal-laded aerogel to temperature in excess of 600 degrees C" (claim 5). However, Struthers do not teach or fairly suggest a method to form a nanostructure laded reticulate structure comprising a step of growing graphite nano-filaments on the reticulate catalyzed carbon aerogel monolith structures.

In light of the above discussion, it is evident as to why the present claims are patentable over the prior art.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ling-Siu Choi whose telephone number is 571-272-1098.

If attempt to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Wu, can be reach on 571-272-1114.

Art Unit: 1713

LING-SUI CHOI PRIMARY EXAMINER

January 21, 2005